



**PATENT**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Application No.: **10/549,609**  
Filing Date: September 20, 2005  
Applicant: Tomoko AKAI et al.  
Conf. No.: 8155  
Group Art Unit: 1746  
Examiner: Margaret Squalls  
Title: METHOD FOR PRODUCING HIGH SILICATE GLASS AND  
HIGH SILICATE GLASS (as amended)  
Atty. Dkt. No.: 12480-000144/US

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Customer Service Window  
Randolph Building  
401 Dulany Street  
Alexandria, VA 22314  
Mail Stop **RCE**

January 20, 2011

**AMENDMENT UNDER 37 C.F.R. § 1.114**

Dear Sir:

In response to the Final Office Action (hereinafter 'Action') mailed on July 22, 2010 (the period for reply being extended three (3) months to January 22, 2011) and concurrently with the filing of a Request for Continued Examination (RCE), the following amendments and remarks are respectfully submitted in connection with the above-identified patent application.

	Claims remaining after Amendment		Highest number previously paid for		Present extra
<b>Total</b>	7	-	20	=	0
<b>Independent</b>	1	-	3	=	0